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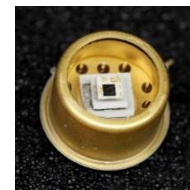
NIR SPADs and fast-gating circuits

Alberto Tosi and SPADlab colleagues

1st International SPAD Sensor Workshop – ISSW 2018
Les Diablerets, February 26th, 2018

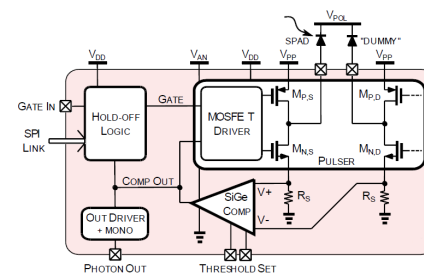
■ InGaAs/InP SPAD

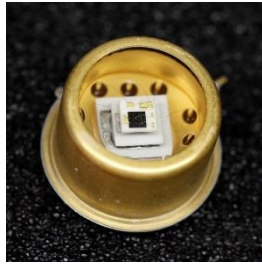
- Device structure
- Performance



■ Circuits for InGaAs/InP SPAD

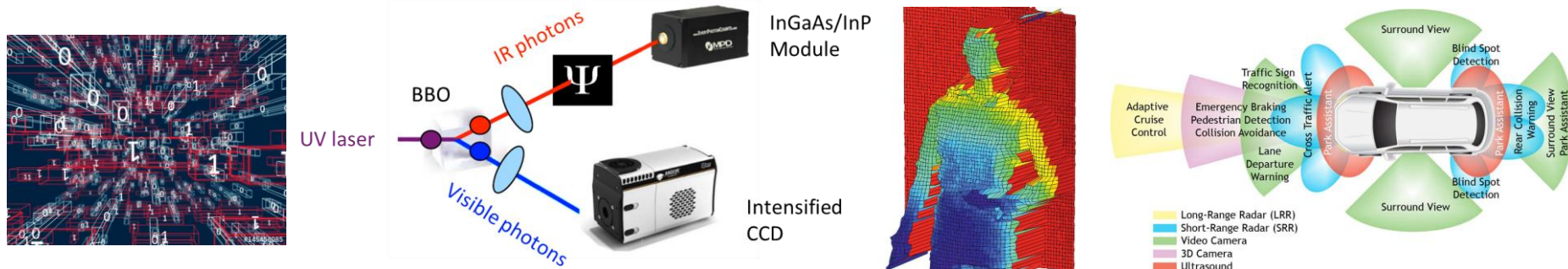
- SPAD with integrated quenching resistor
- GHz sinusoidal gating
- Integrated fast-gated active quenching circuit (ASIC)





InGaAs/InP SPAD

- Quantum Information Processing and Communication
- Quantum Key Distribution (QKD)
- Eye safe ranging (LIDAR)
- Unconventional (ghost, non-line-of-sight, ...) imaging
- Time-resolved diffused optical spectroscopy
- Photodynamic therapy (PDT) for cancer treatment
- Optical testing of VLSI circuits
- Photonics research in the 1 μm – 1.6 μm range



Detector + electronics tailored for the specific application!

Photons up to $\sim 1.6 \mu\text{m} \rightarrow E_g < 0.8 \text{ eV} \rightarrow \text{InGaAs}$ ($E_g \sim 0.75 \text{ eV}$)

But low E_g means:

- higher noise \rightarrow **cooling** is mandatory ($T \sim 230 \text{ K}$)
- strong tunneling \rightarrow higher E_g material is required for avalanche \rightarrow **InP** with $E_g \sim 1.35 \text{ eV}$



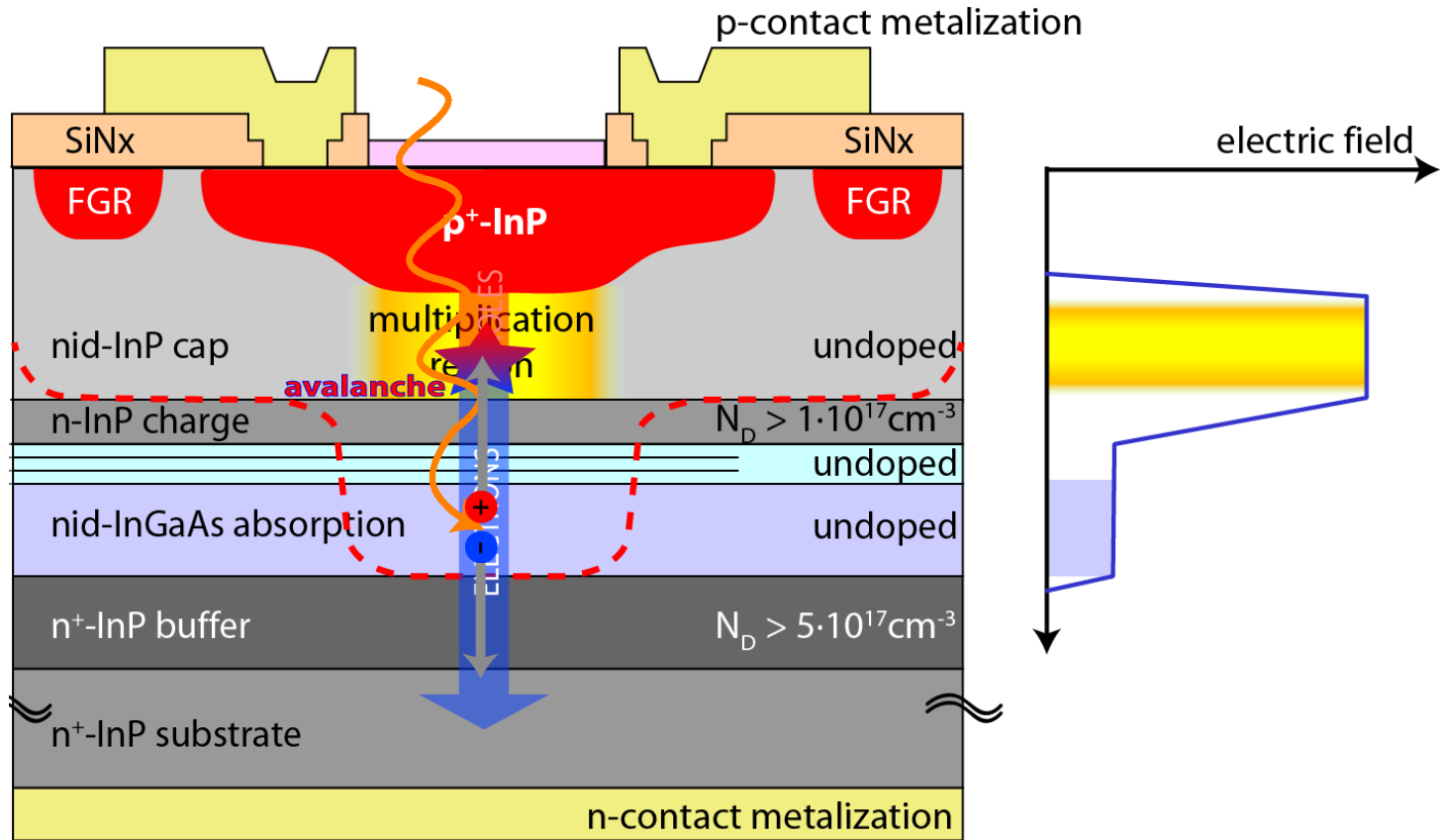
Separate Absorption, Charge and Multiplication (SACM)

- **Absorption:** $\text{In}_{0.53}\text{Ga}_{0.47}\text{As}$ ($E_g \sim 0.75 \text{ eV}$)
- **Charge:** **highly-doped InP** ($E_g \sim 1.35 \text{ eV}$)
- **Multiplication:** **InP** ($E_g \sim 1.35 \text{ eV}$)

Planar technology (no MESA) for lower noise and higher reliability

Front-illuminated structure \rightarrow Well-defined collection area

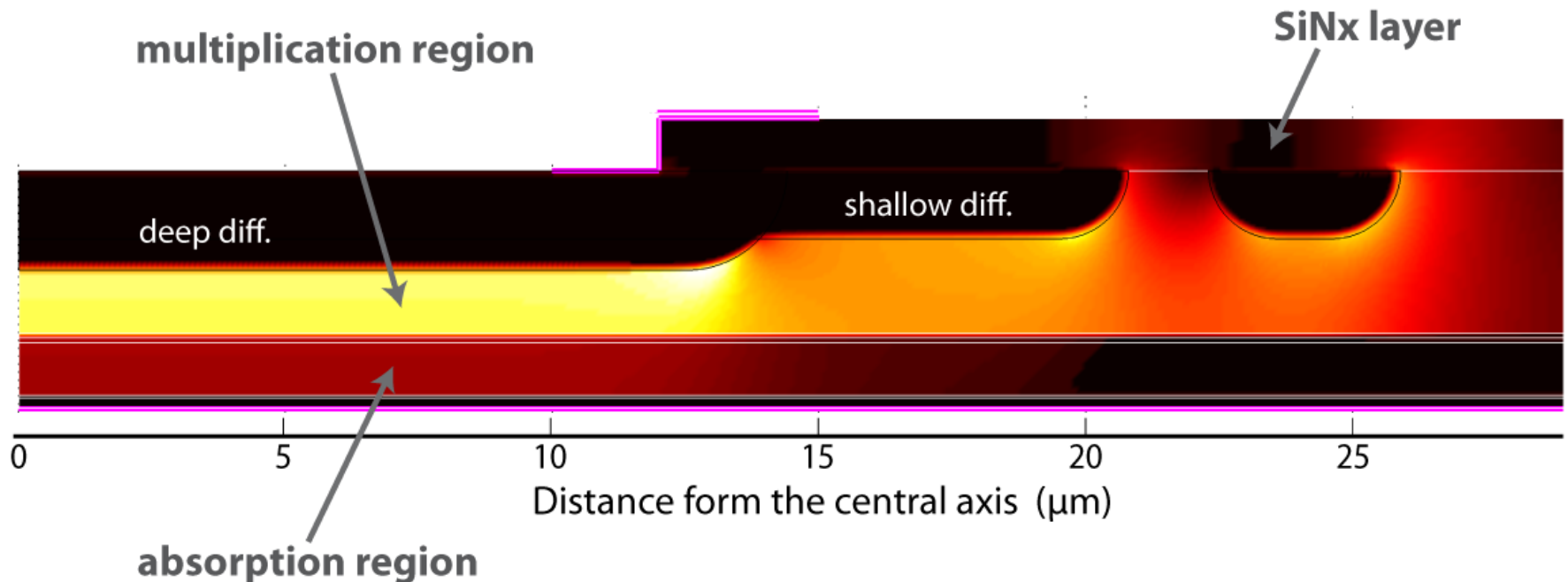
Back-illuminated structure \rightarrow Suitable for arrays



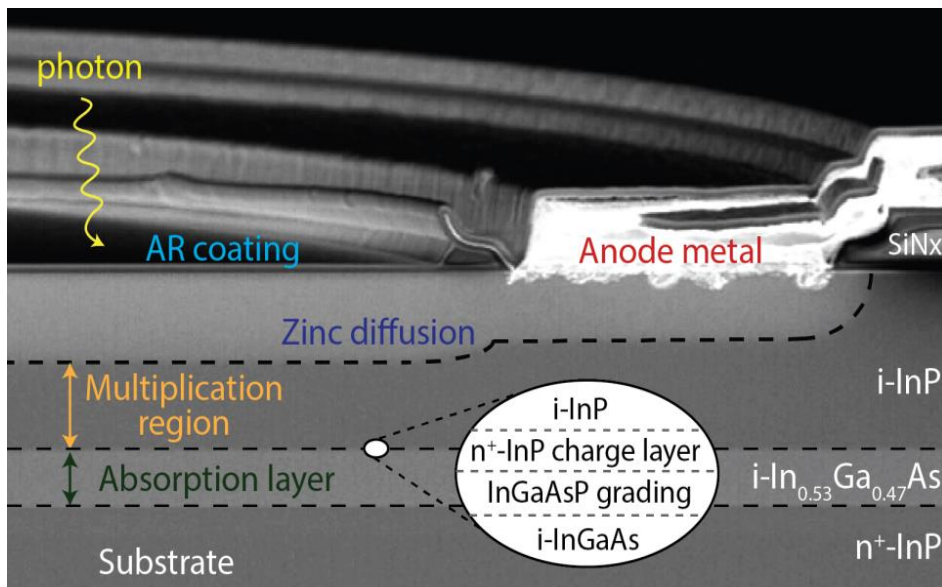
(Front-illuminated structure)

- Optimized double Zn diffusion (depths and diameters)
- good uniformity in the active area ($\Delta V_{BD} < 4\%$)
 - no activation in the periphery

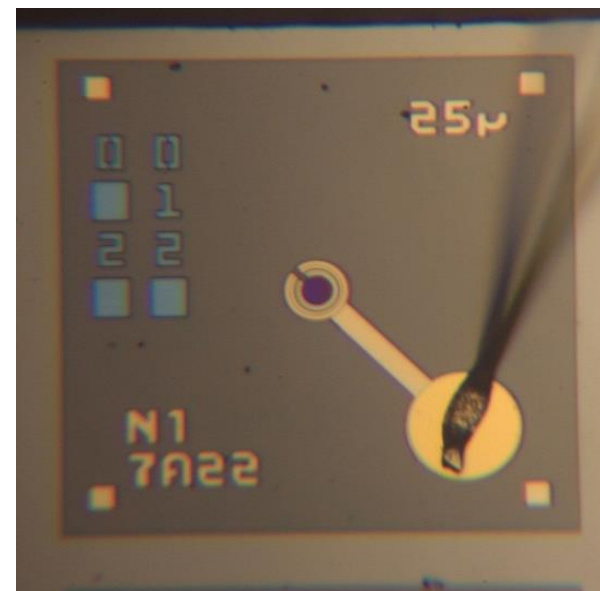
→ **Uniform sensitivity and low timing jitter**



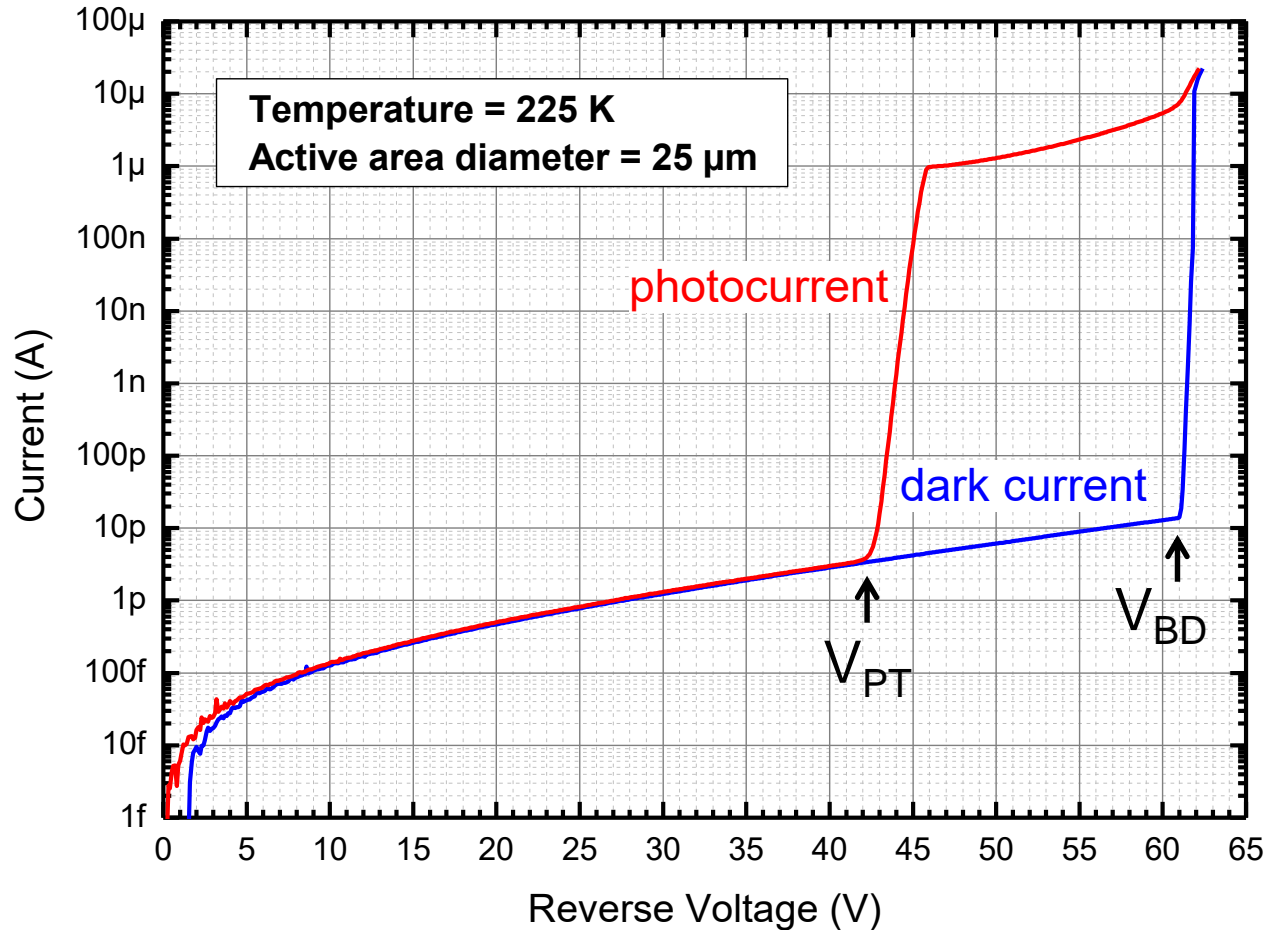
(Electric field simulation at 200 K & $V_{EX} = 5$ V)



(SEM cross-section)

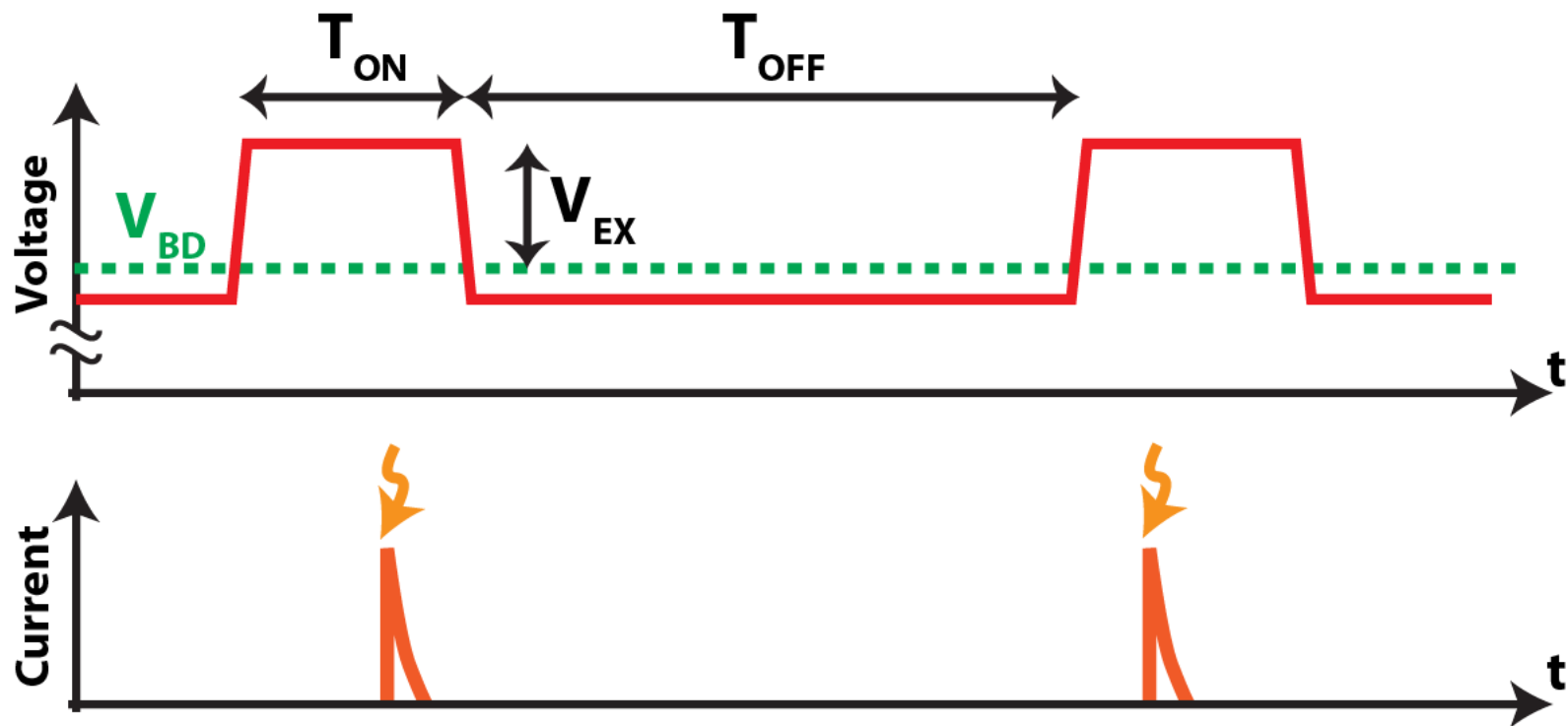


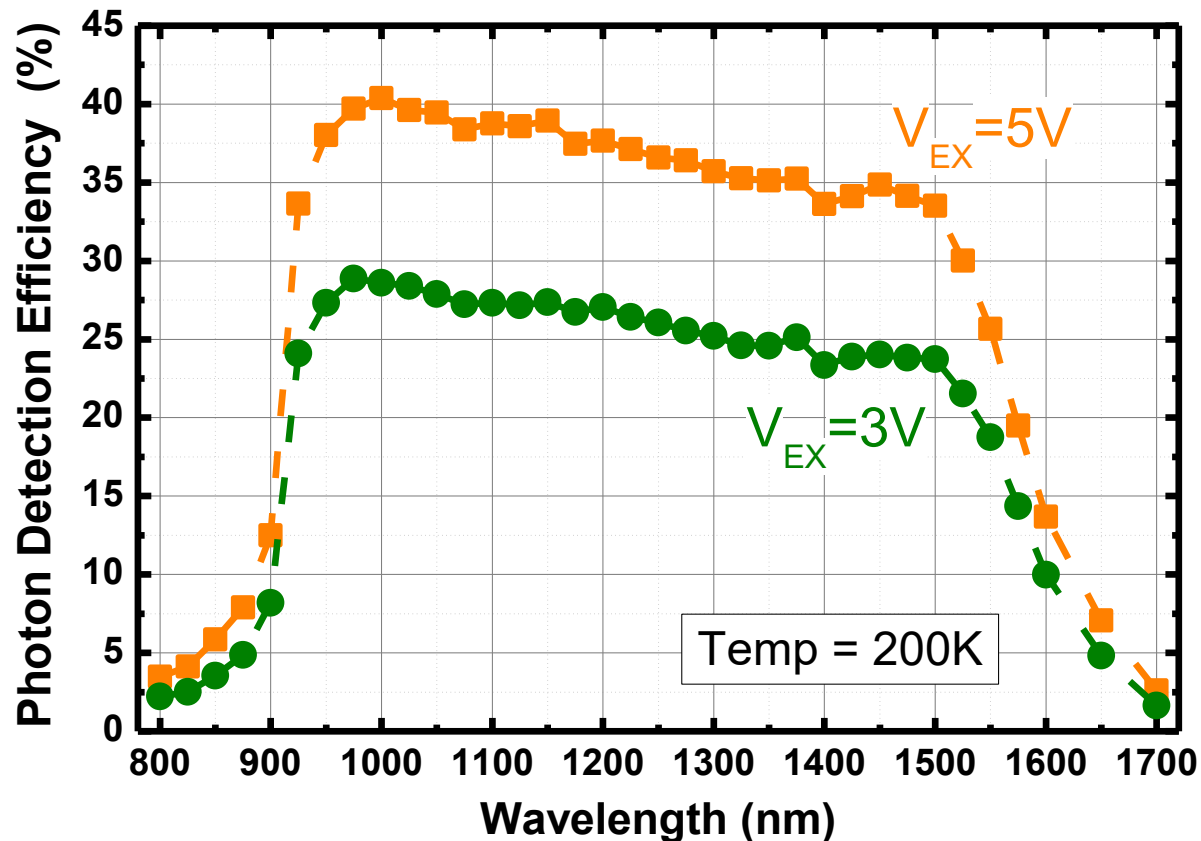
(top view)



Low dark current: $I_{\text{dark}} \sim 10 \text{ pA} @ V_{\text{BD}} - 1 \text{ V}$,
sharp breakdown knee, large $V_{\text{BD}} - V_{\text{PT}}$ difference

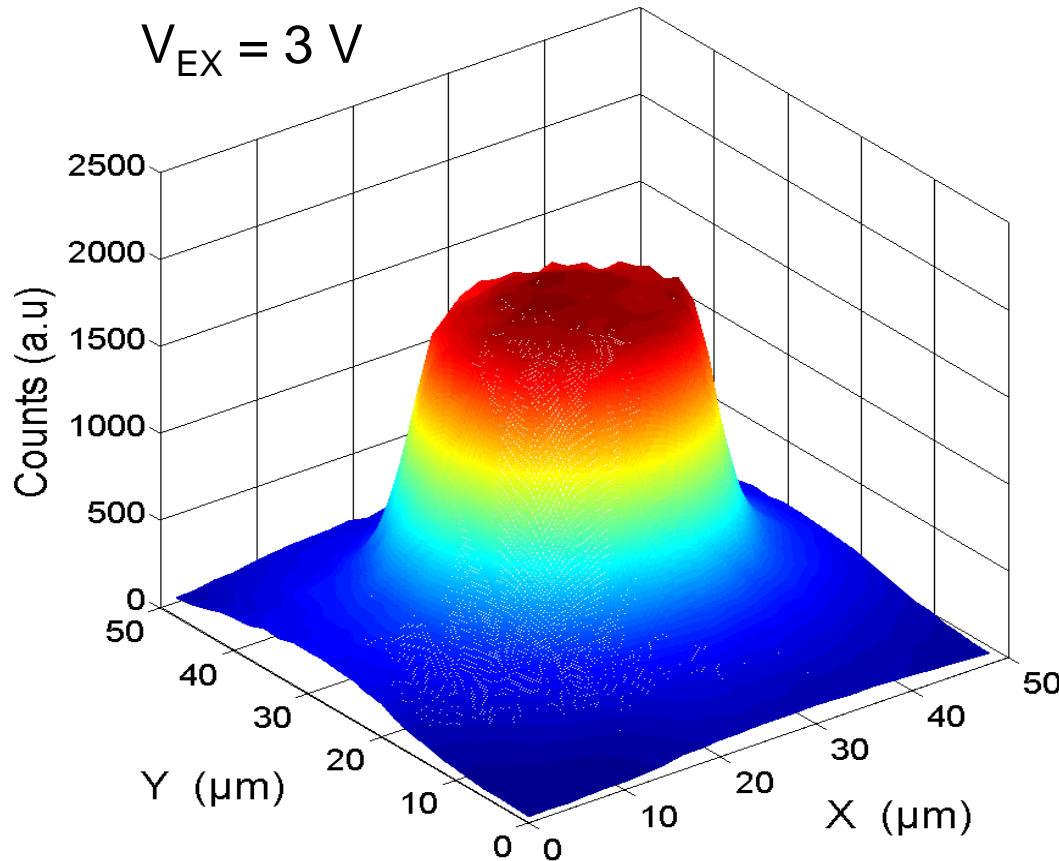
- SPAD is enabled during **Gate-ON time**
- SPAD is held OFF to empty traps \rightarrow reduce afterpulsing
- **Gate period** $T_{\text{GATE}} = T_{\text{ON}} + T_{\text{OFF}}$





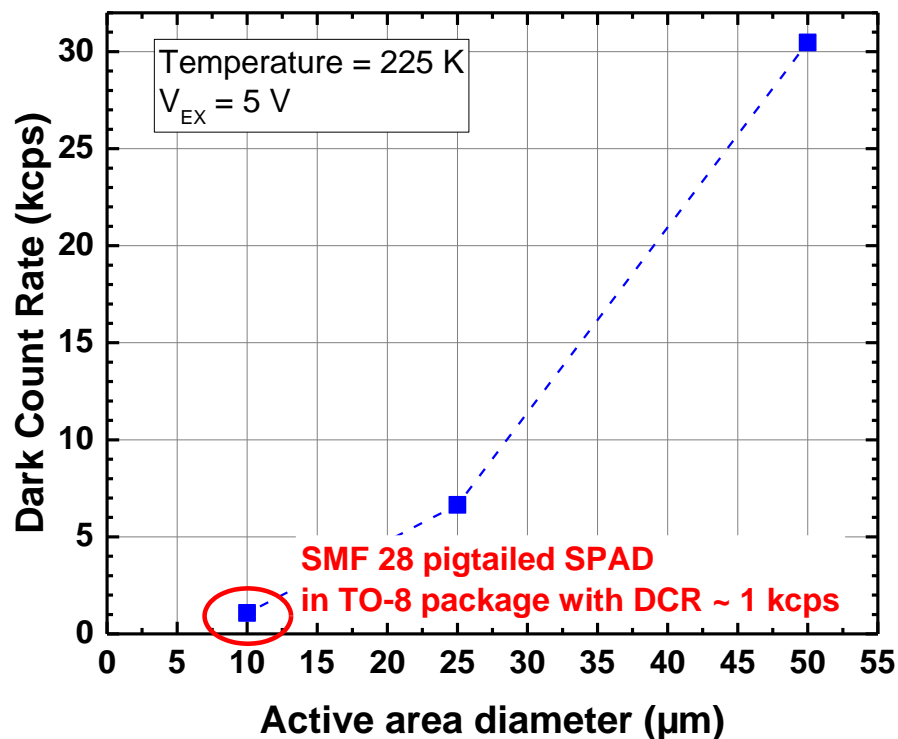
Good photon detection efficiency:

- 40% @ $\lambda = 1000$ nm, $V_{EX} = 5$ V
- 25% @ $\lambda = 1550$ nm, $V_{EX} = 5$ V
- still 3% @ $\lambda = 1700$ nm, $V_{EX} = 5$ V

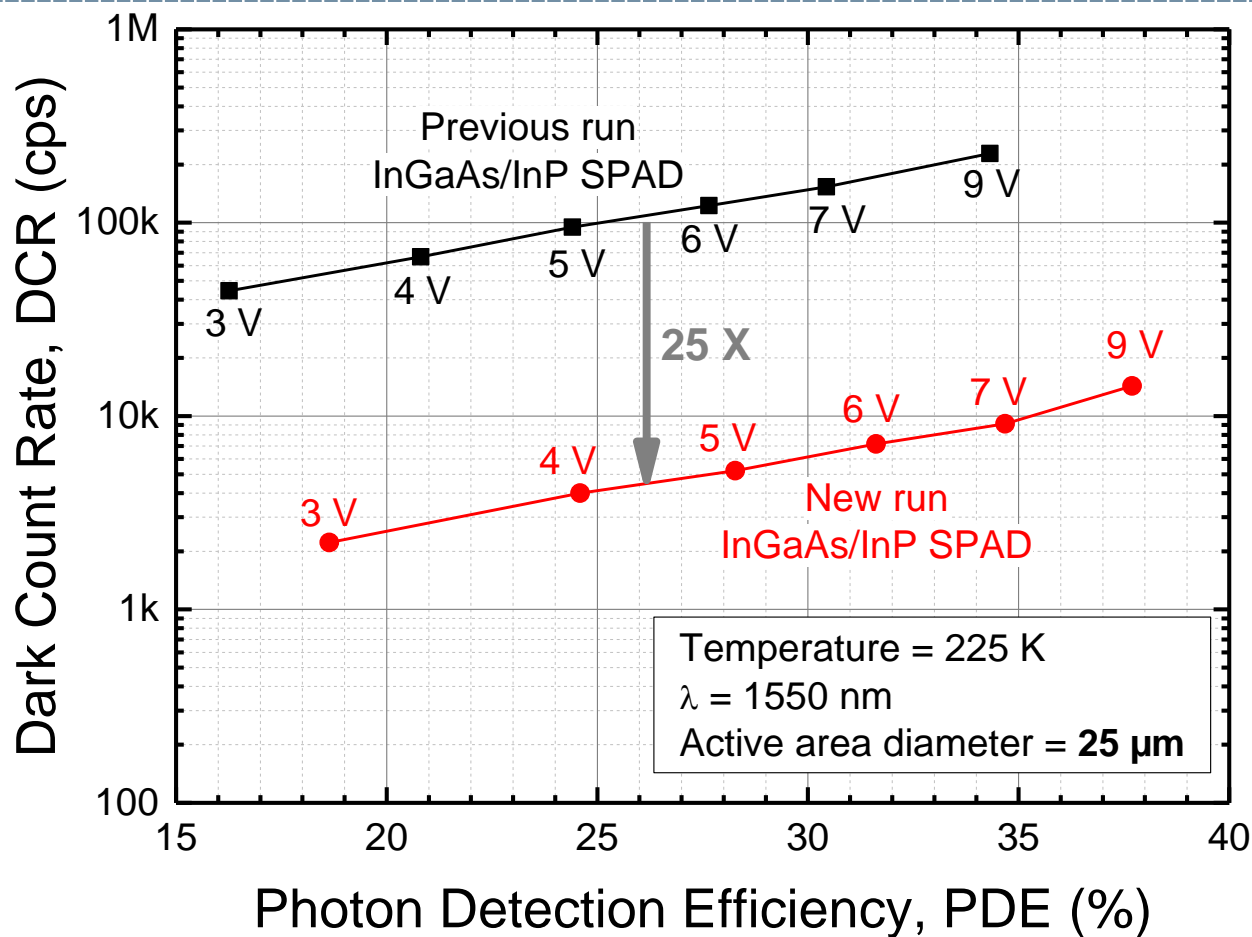


- Uniform sensitivity within the active area
- Sharp edges

Uniformity improves at higher excess bias
(due to saturation of avalanche triggering probability)

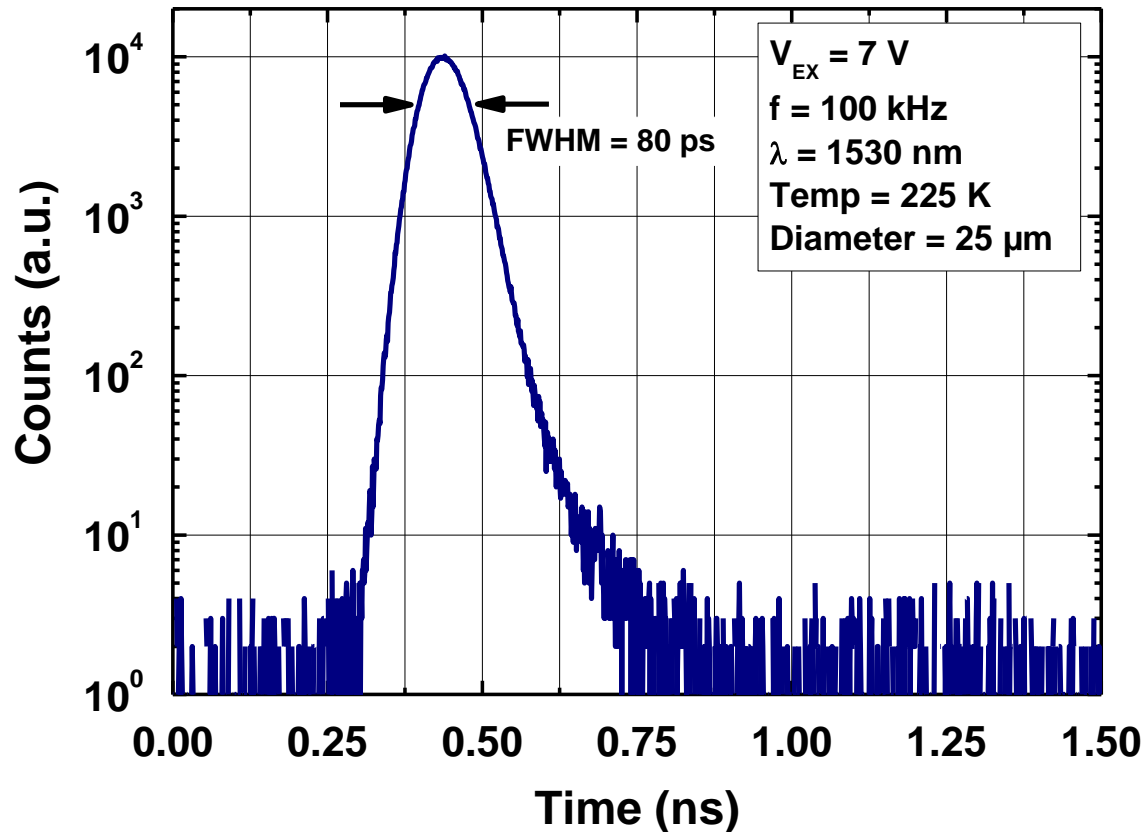


- DCR scales with active area \rightarrow bulk origin
 (while dark current scales with perimeter, i.e. it is peripheral leakage)
- 10 μm InGaAs/InP SPAD with DCR of few kcps
- 10 μm SPADs have been fiber pigtailed (Micro Photon Devices – MPD)



25 times lower DCR at a given PDE by improving SPAD design

→ There is room for further improvement!



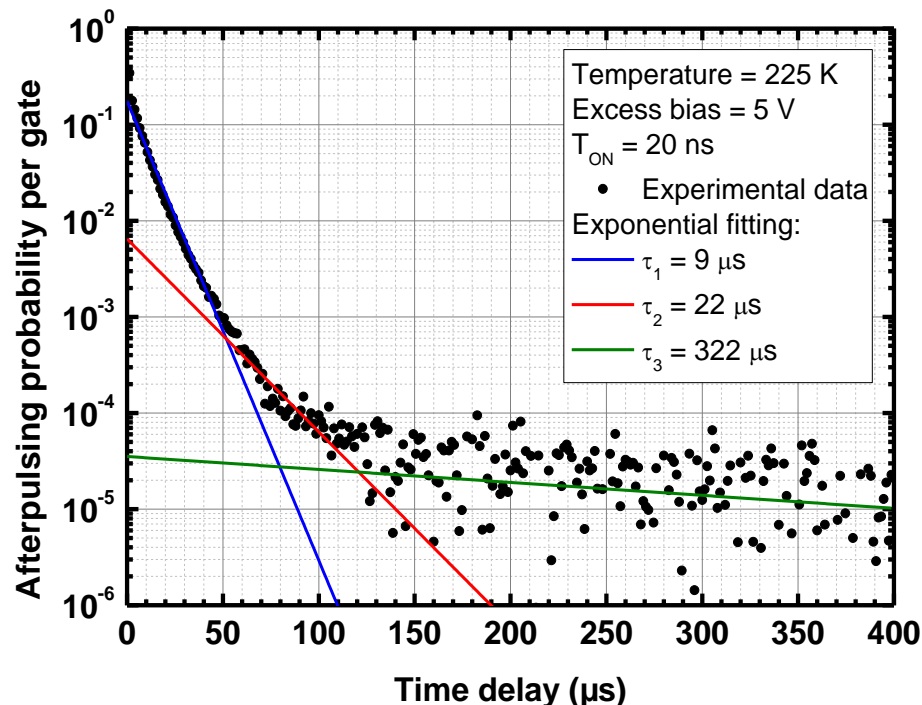
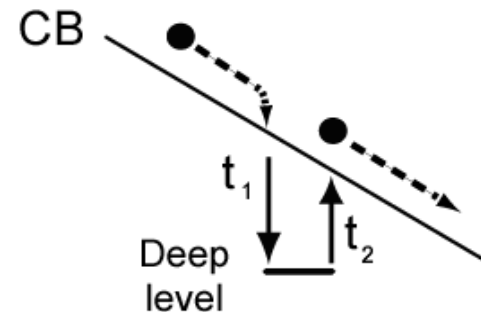
Sharp and “clean” time response FWHM < 80 ps @ 7 V

- Near **Gaussian** distribution
- **Short exponential tail** ($\tau = 58 \text{ ps}$)

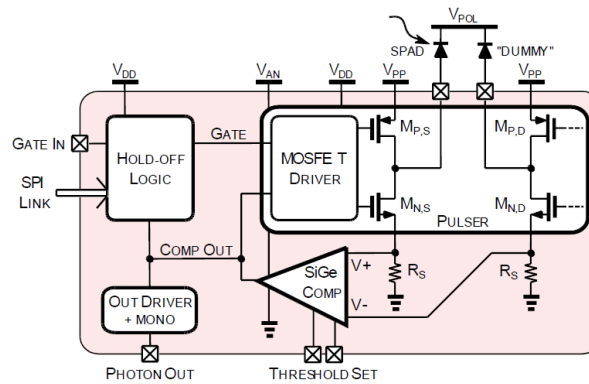
Main drawback of InGaAs/InP SPADs: **afterpulsing**

- Some avalanche carriers get trapped in deep levels in InP multiplication region
- Delayed release triggers “afterpulse” avalanches

➔ **Limitation to maximum count rate**



Here is an example where different traps release carriers with different time constants (10's or even 100's μs !)



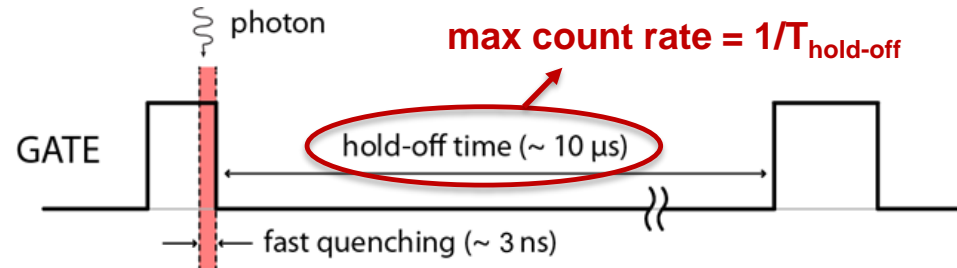
Circuits for high count rate InGaAs/InP SPAD systems

Reduce concentration of deep levels

→ challenging task (improved fabrication process)

Long hold-off time before re-arming

→ not an option at high rates



Reduce avalanche carriers

fast quenching (monolithically integrated passive quenching or ASIC)

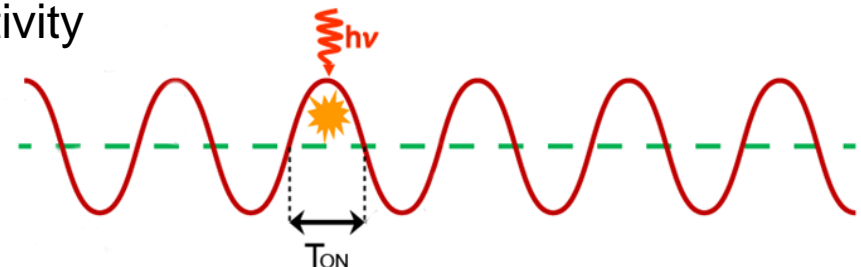
→ either gated or free-running mode

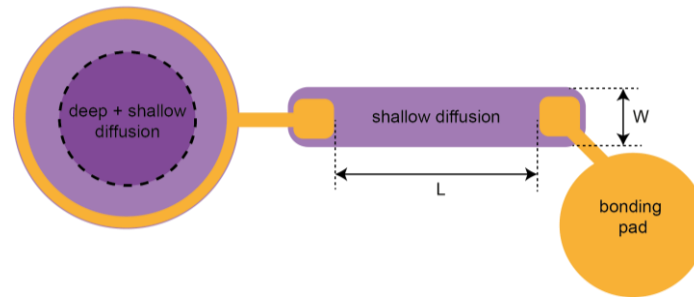
→ moderately high count rates (1–10 MHz)

short gates ($\ll 1$ ns): → very high (> 100 MHz) count rates

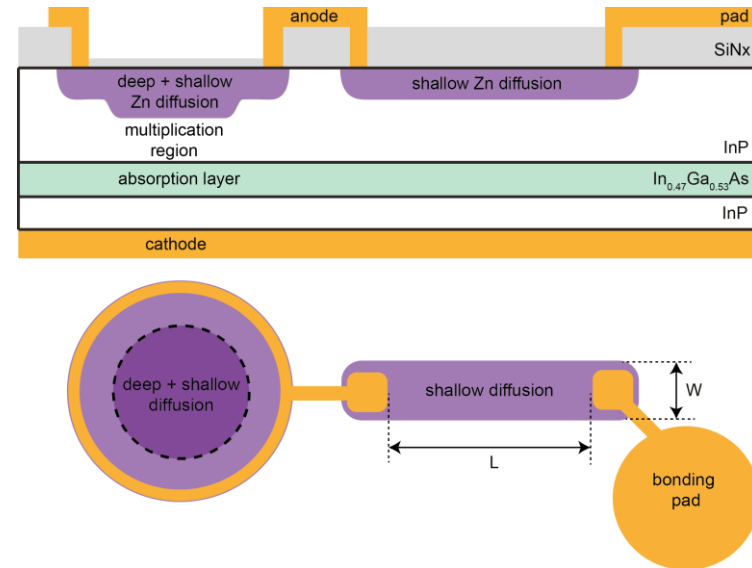
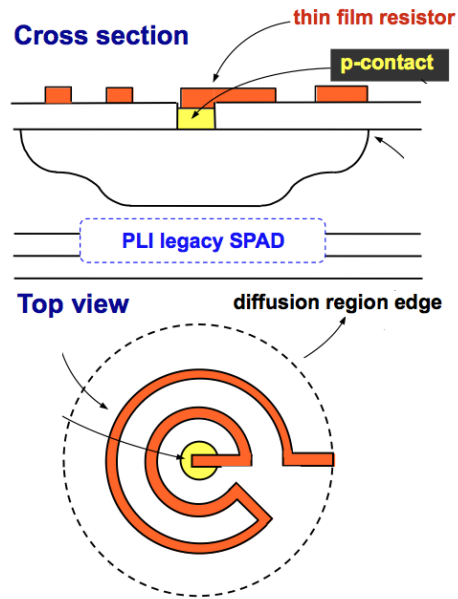
→ complex RF transients suppression

→ non-flat sensitivity





SPAD with integrated quenching resistor

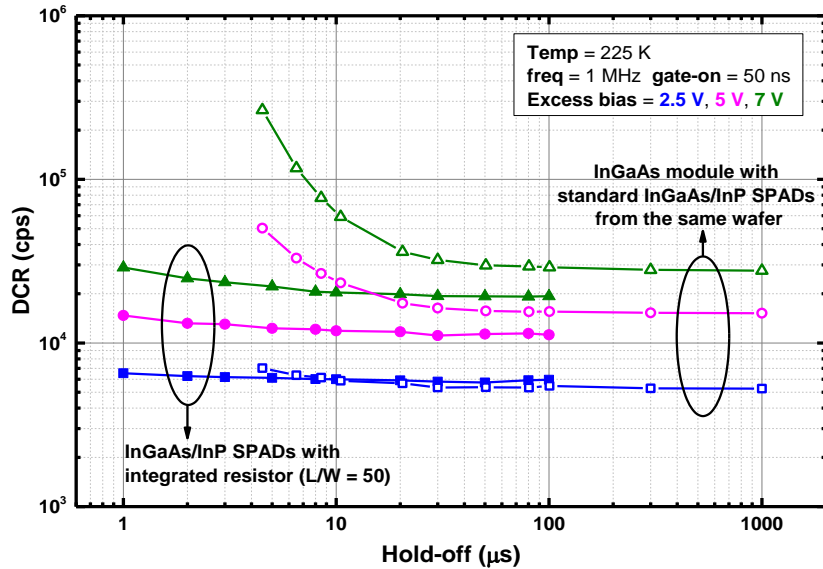


Others' implementation (PLI NFAD):

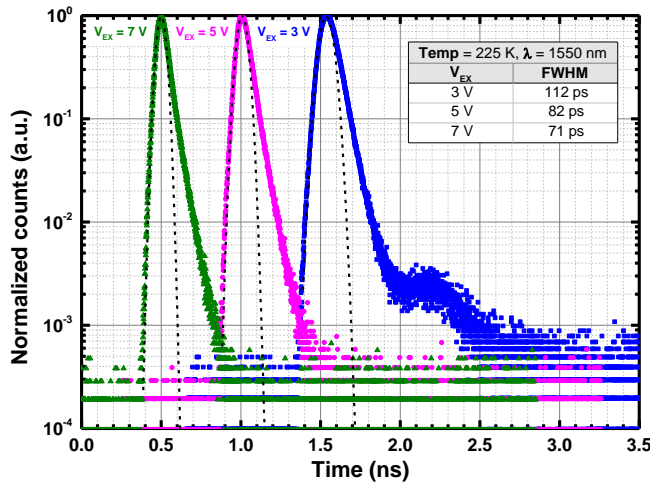
- Thin film resistors (up to $\text{M}\Omega$)
- Additional fabrication steps and masks required
- Slow re-arm ($100 \text{ ns} \div 1 \mu\text{s}$)

PoliMi implementation:

- **No additional fabrication steps:**
Zn shallow diffusion exploited
- $\text{k}\Omega$ resistor: - quasi-quenching
- **faster re-arm** ($< 100 \text{ ns}$)

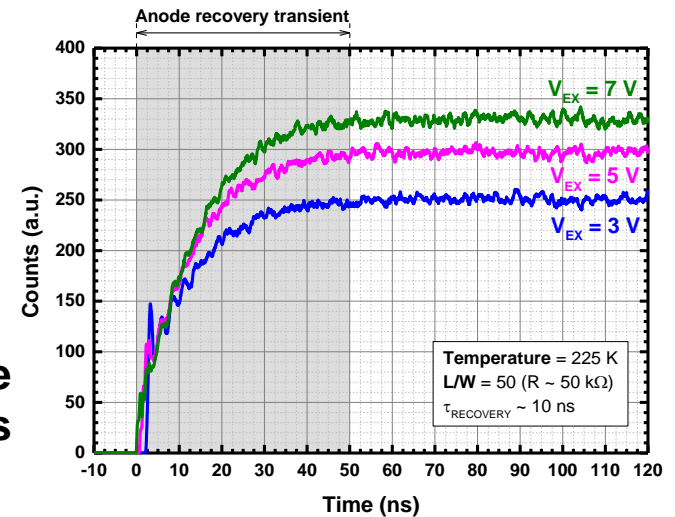


Significant afterpulsing reduction



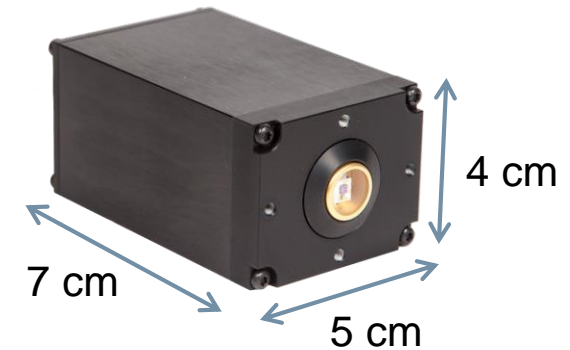
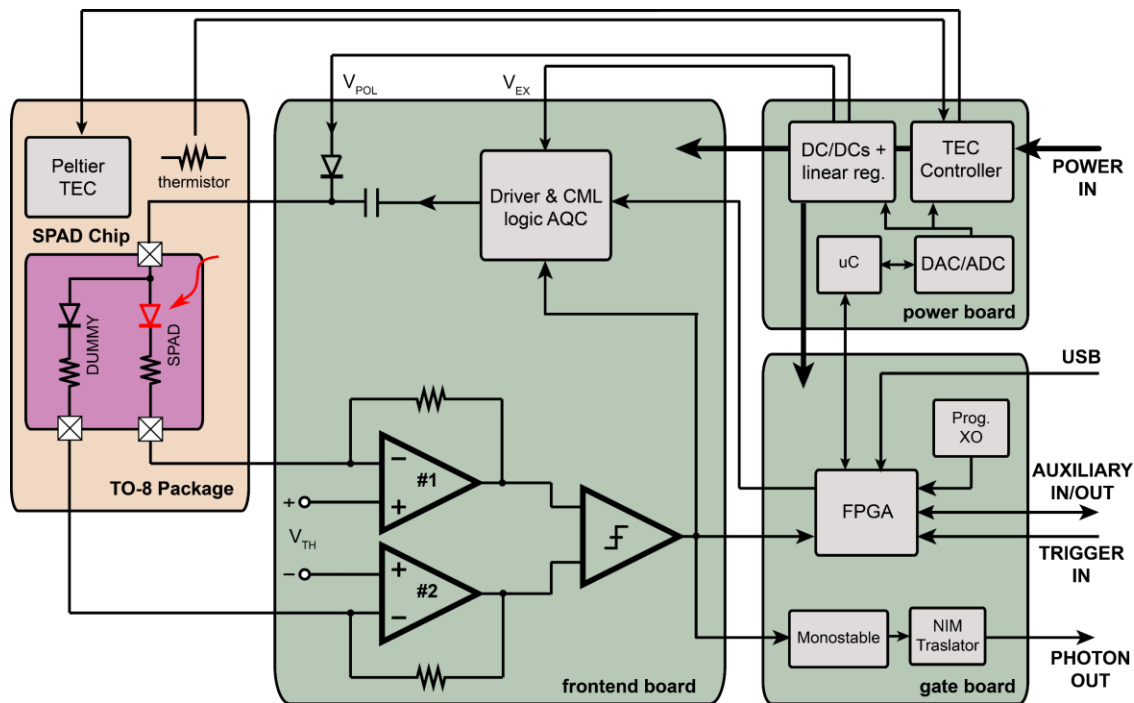
Good temporal response

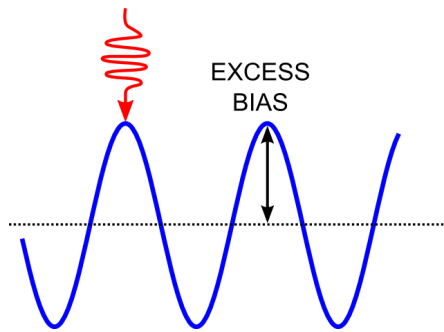
Faster recovery time with $\tau = 10$ ns



Detector, front-end electronics and cooling housed in a small case

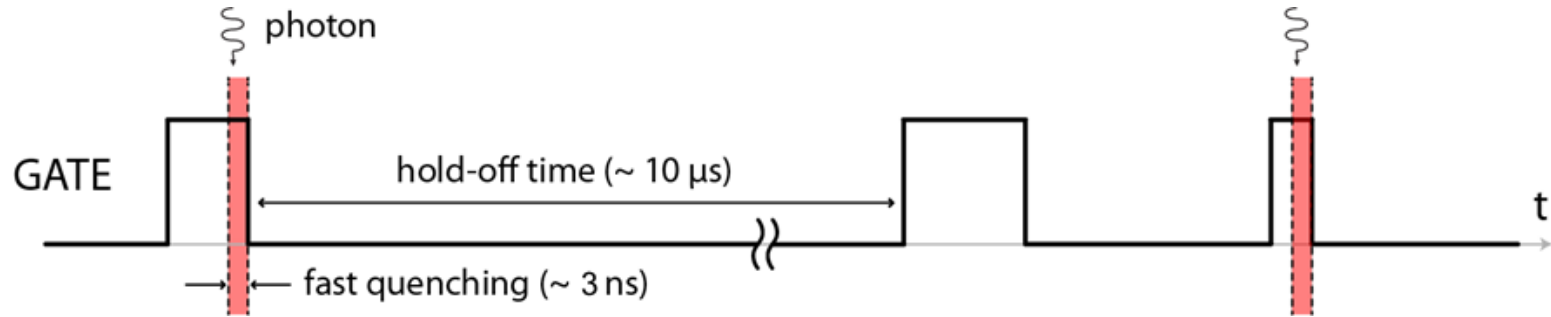
- Easy integration in optical setups
- Easy to use and configurable





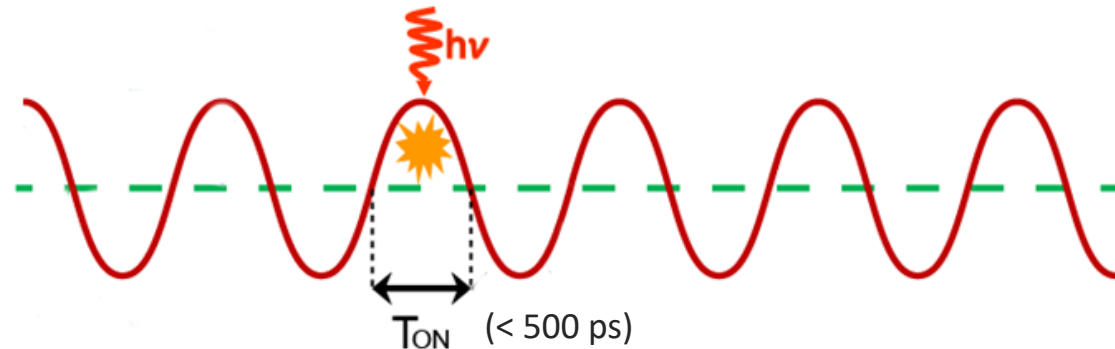
GHz sinusoidal gating with SPAD-dummy balancing approach

Square-wave gate

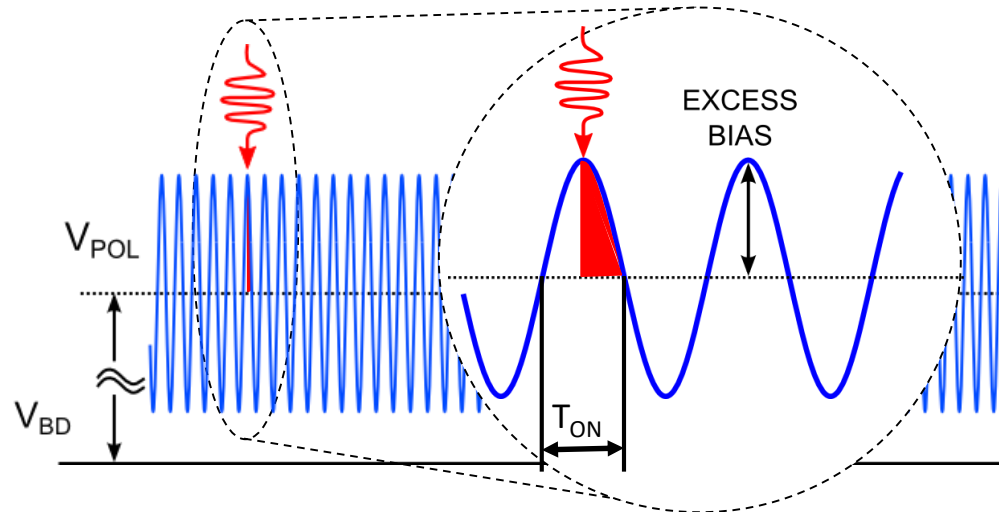


- ✓ Flat sensitivity (few %)
- ✓ Low time jitter (< 100 ps)
- ✗ High avalanche charge
- ✗ Low count rate

GHz sine-wave gate



- ✓ Short quenching time
- ✓ Very high count rate
- ✗ Complex systems
- ✗ Non-flat sensitivity



Gate signal at $f_G > 1$ GHz for fast avalanche quenching

f_G tunable in a wide range (900-1400 MHz) for:

- Synchronization with different external laser systems
- Best trade-off between afterpulsing and detection efficiency

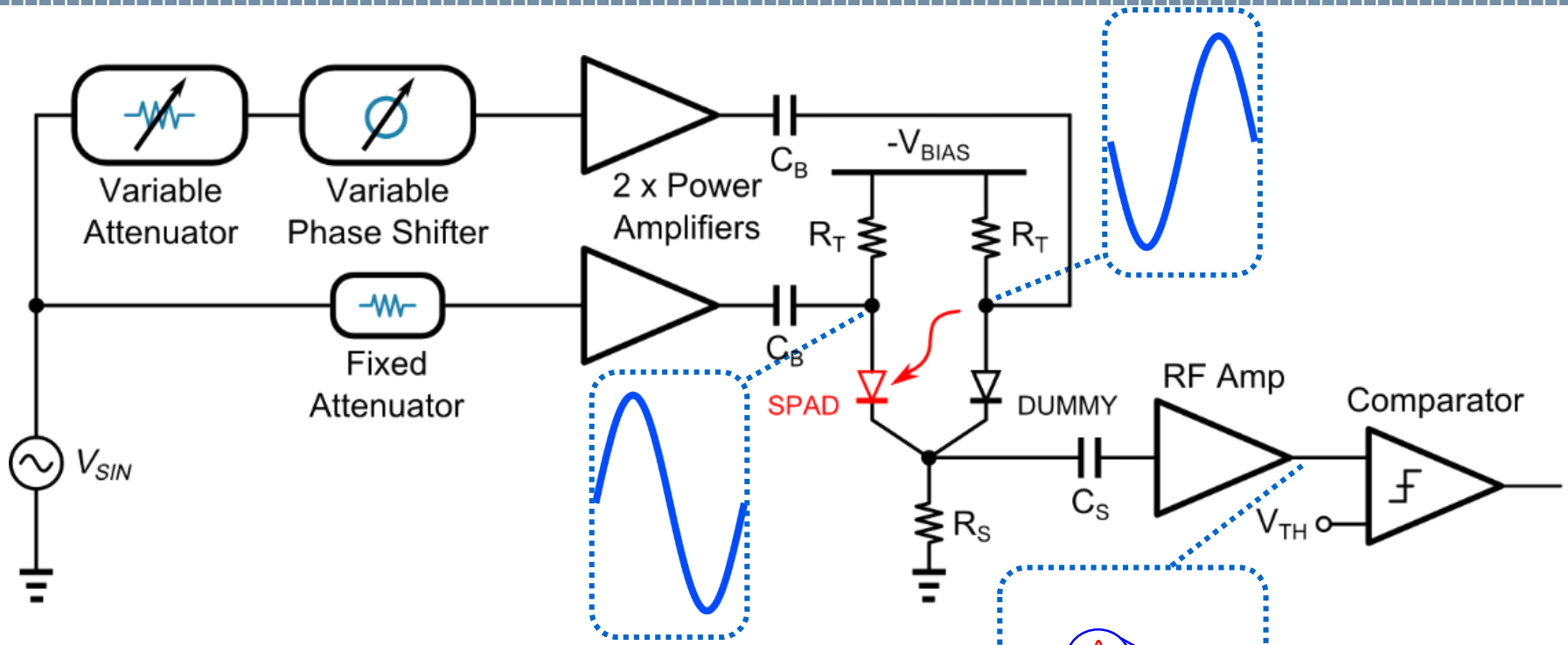
Adjustable excess bias:

- for optimizing PDE, DCR, afterpulsing, timing jitter
- Up to 7 V (27 dBm!)

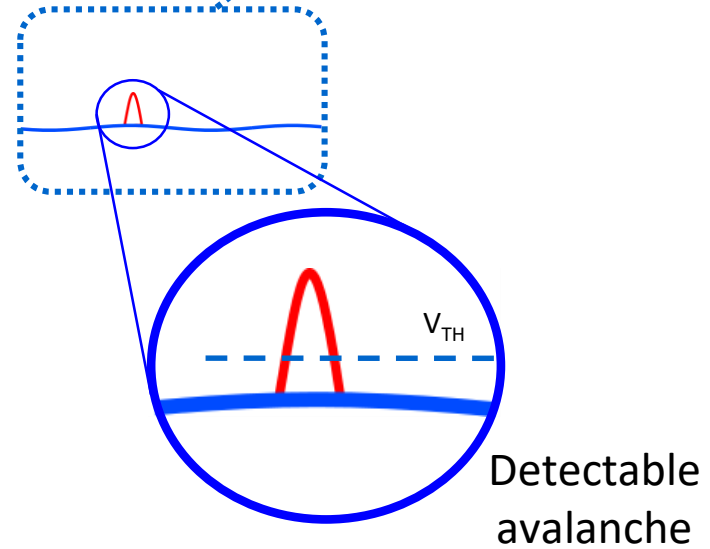
Long-term stability

- Feedback for gate feed-through rejection

Suitable for rack mounting

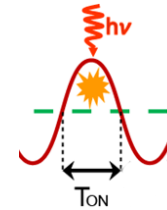


- SPAD – Dummy couple
- Two gate sinusoidal signals in anti-phase for cancelling capacitive feedthrough
- Tunable wideband components (amplitude matching within 0.1%, phase matching within 0.05°)



PoliMi sine-wave gate results:

(compared to square-gate system with similar SPAD)

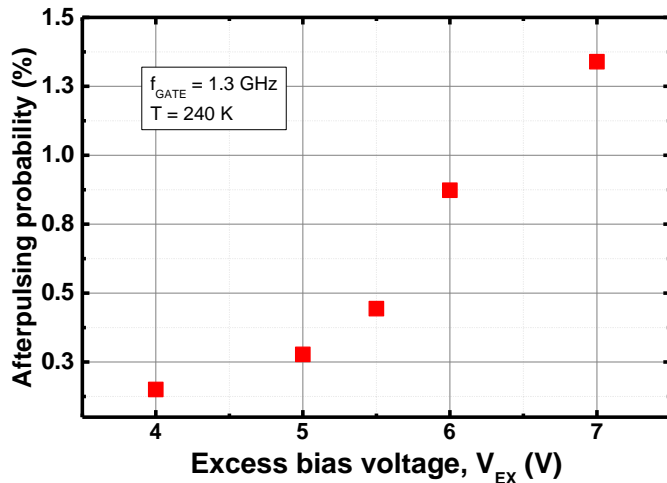


At the same low afterpulsing probability:

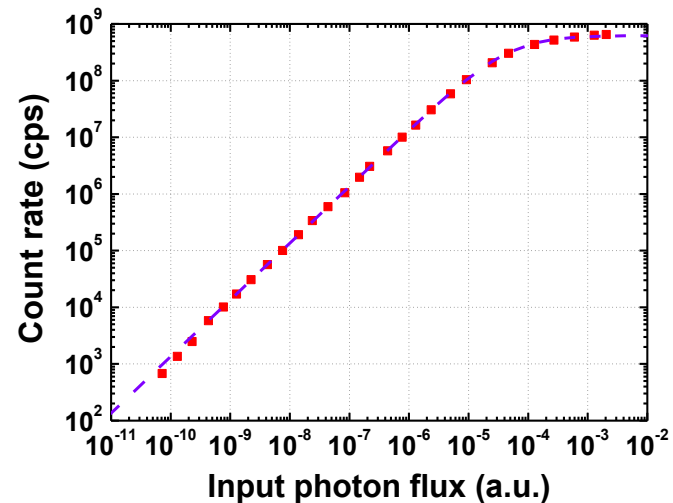
✓ Very high count rate	650 Mcps	1.5 %	1.5 % (*)
✓ Good peak detection efficiency	~ 30 %	< 100 kcps	~ 30 %
✓ Narrow temporal response	< 70 ps	< 70 ps	< 70 ps

All results with 7 V excess bias unless specified – (*) $T_{ON} = 5 \text{ ns}$, $T_{HO} = 10 \mu\text{s}$

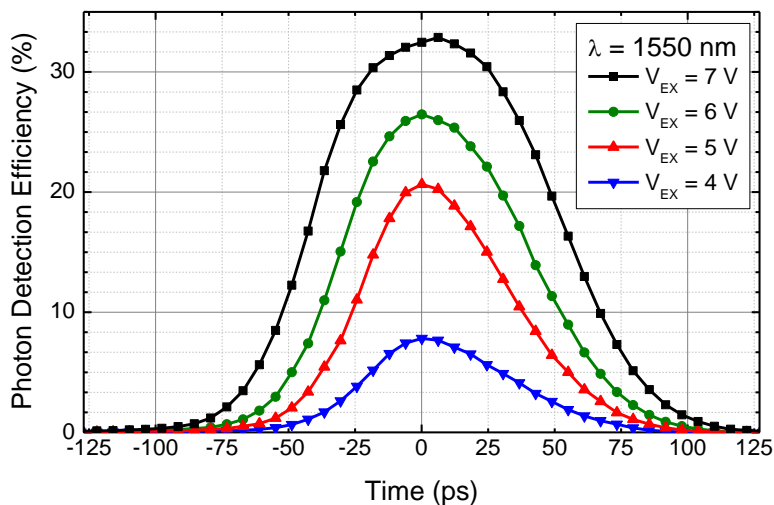
Afterpulsing probability



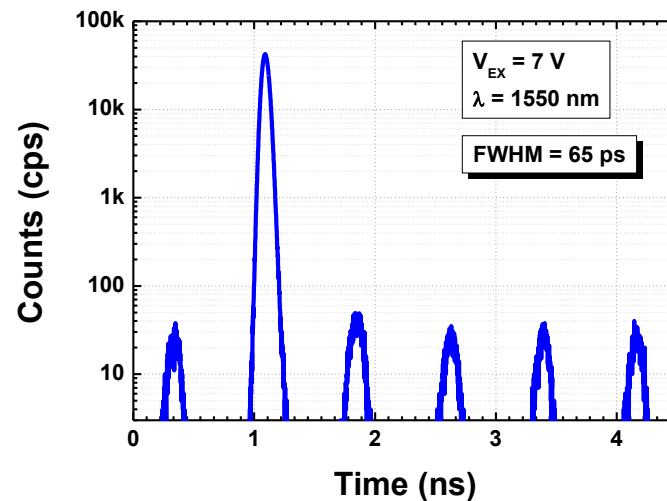
Linearity



Photon detection efficiency



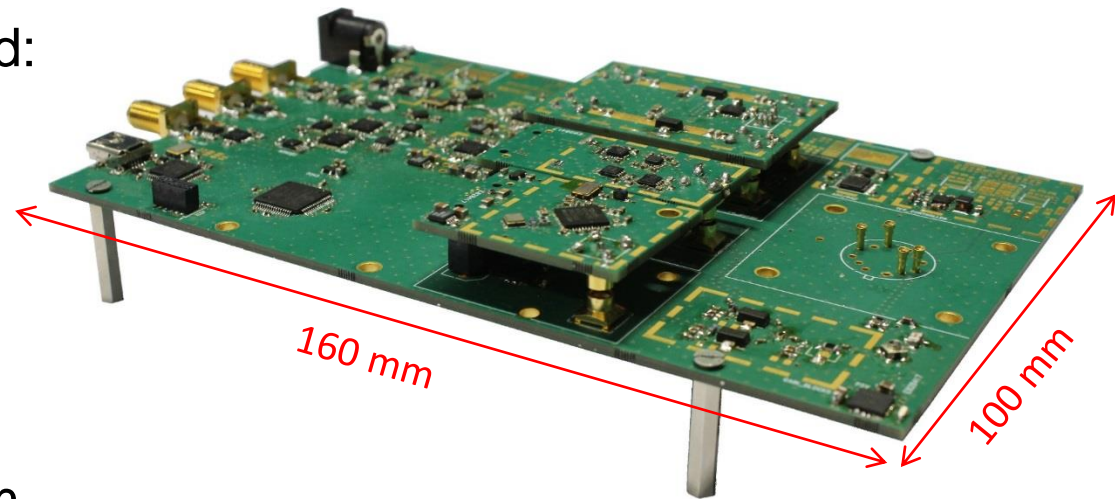
Temporal response



Main board of the new system:

- All the basic blocks on board:

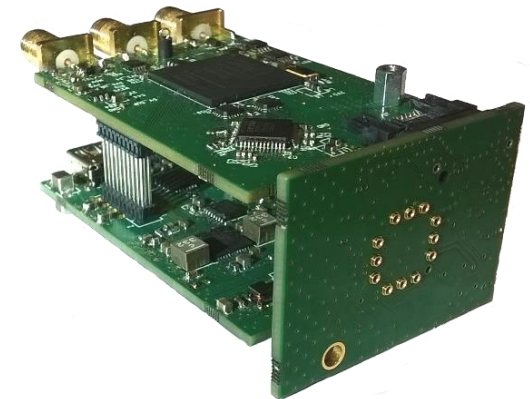
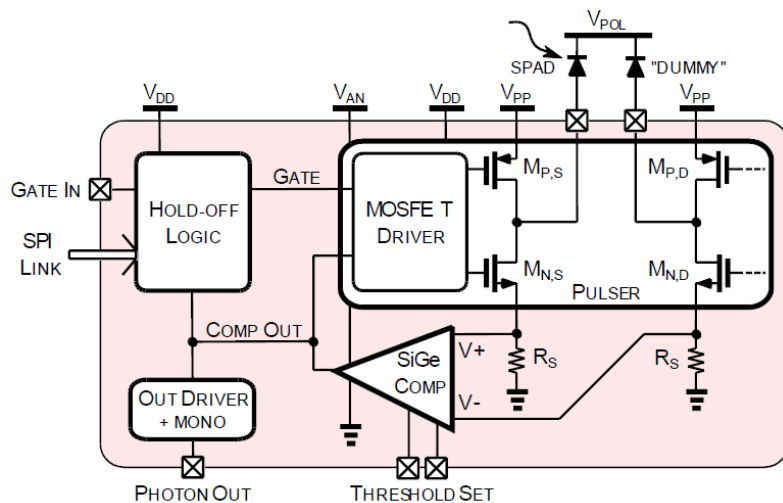
- Gate generation
- Gate amplification
- Avalanche readout
- Feedback control system



- PLL with multiple outputs generates both gate signals (800 – 1500 MHz)
- Programmable gain amplifier to set gate amplitude (up to $V_{EX} = 7$ V)
- Readout amplifiers with 3 GHz bandwidth and ultrafast comparator



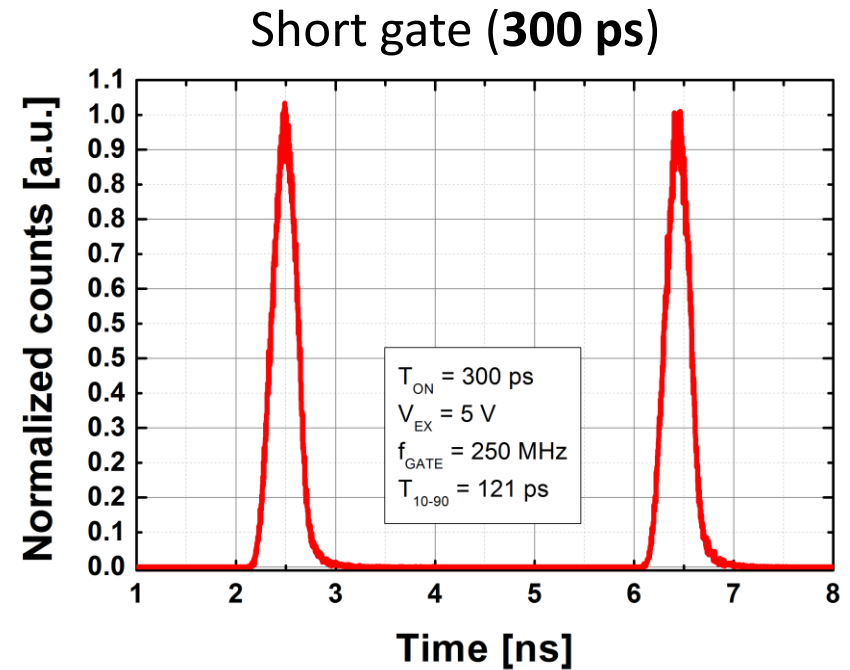
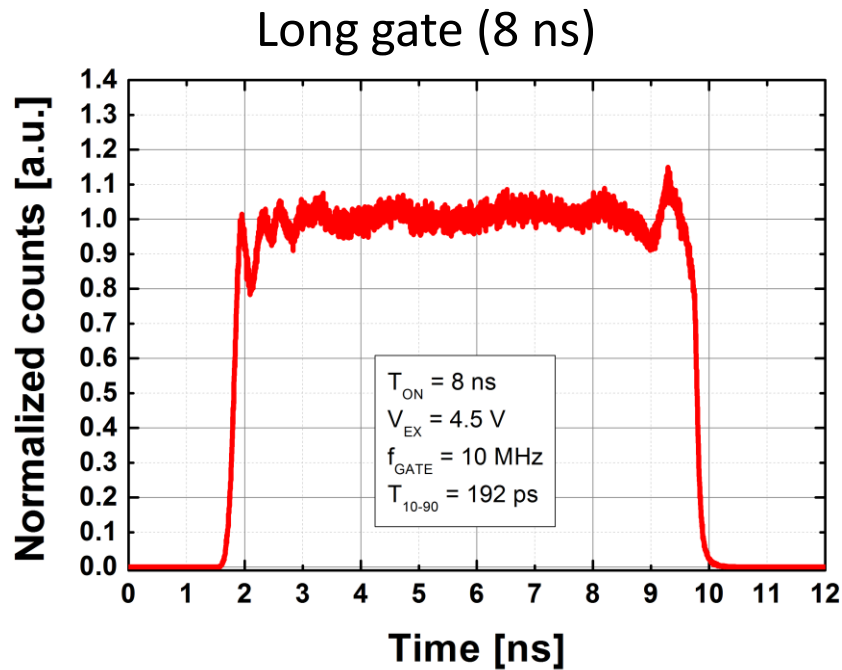
SiGe integrated circuit for fast gating SPADs



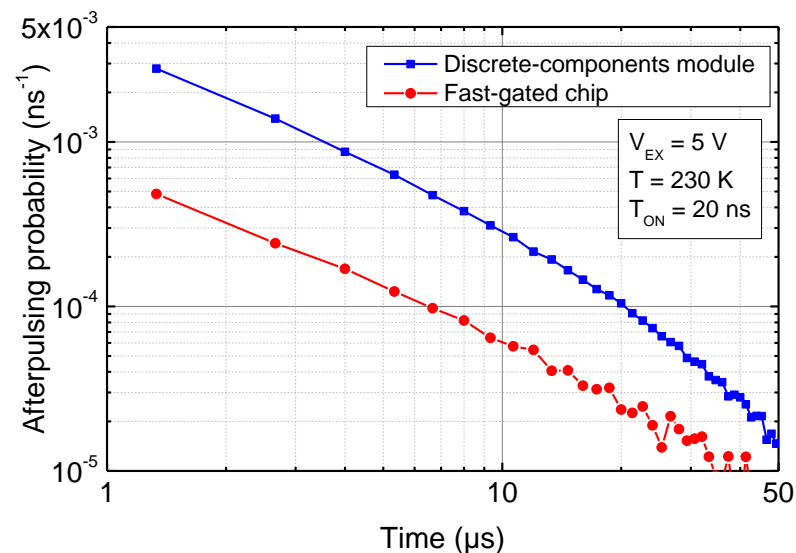
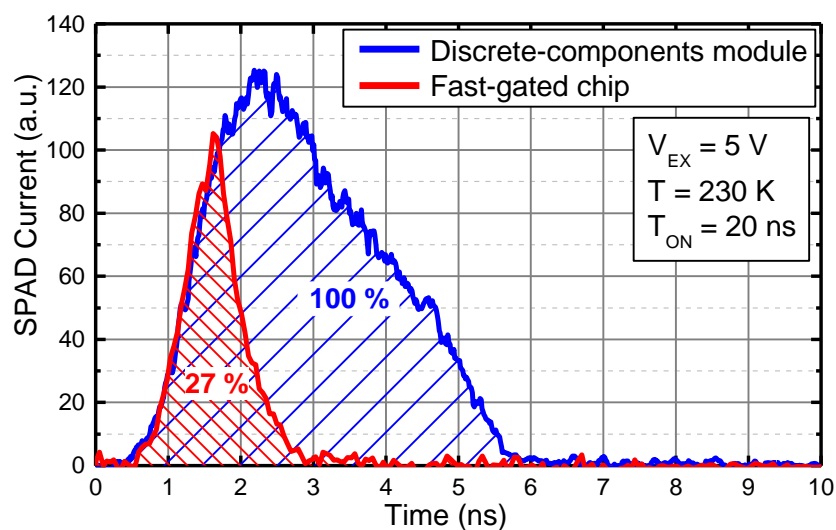
Integrated circuit (SiGe BiCMOS technology):

- SPAD front-end based on “SPAD-dummy” approach
- Quenching time < 1 ns
- Very fast transition times (< 200 ps @ $V_{EX} = 5$ V)
- High repetition rate (up to 250 MHz)
- Low timing jitter (FWHM < 90 ps with InGaAs/InP SPAD, intrinsic < 20 ps)
- Mounted in a 12 pin TO-8 package \rightarrow compact module
- Ready for arrays!

- Very fast rise/fall edges (< 200 ps @ $V_{EX} = 5$ V) \rightarrow **short gate (300 ps)**
- Flat sensitivity ($\pm 15\%$) inside long gate windows
- Free-running mode available

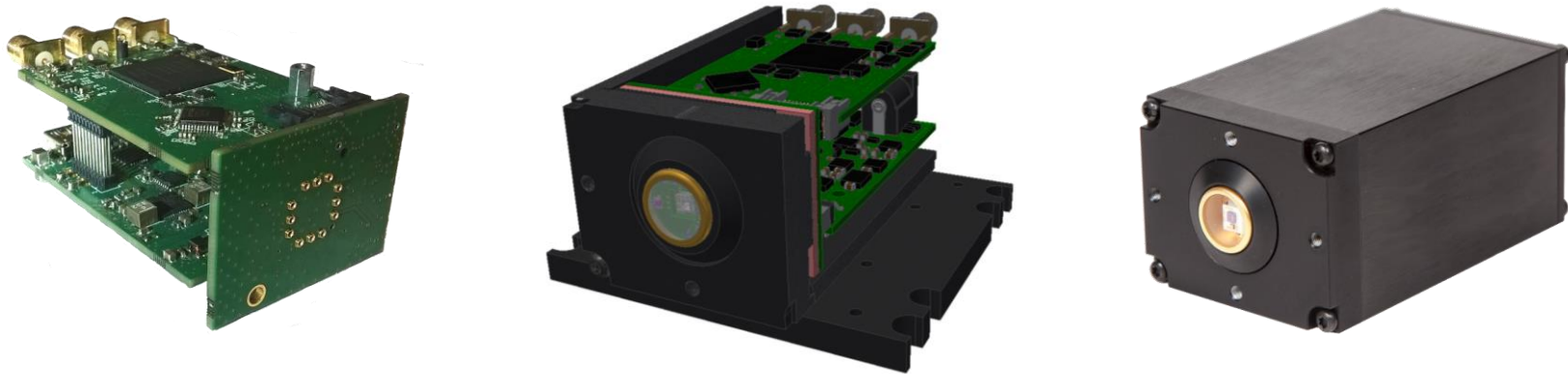


Effective reduction of avalanche charge
 → lower afterpulsing even with long gate



5X reduction of afterpulsing
 with long gate

Compact module based on integrated circuit & InGaAs/InP SPAD



Maximum gate repetition rate	250 MHz
Hold-off time	0.003 ÷ 1300 μ s
Gate width	0.3 ÷ 1000 ns
SPAD temperature	205 ÷ 290 K
Size	40 x 50 x 70 mm ³

■ InGaAs/InP SPAD:

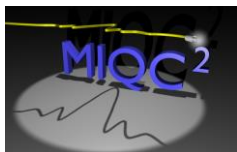
PoliMi experimental results (@ $V_{EX} = 5$ V):

- Low DCR ($\sim 10^3$ at 225 K)
- Good detection efficiency (30 % @ 1550 nm)
- Moderately low afterpulsing
- Low timing jitter (FWHM < 90 ps)

■ Circuits for high-count-rate InGaAs/InP SPAD system:

- SPAD with integrated quenching resistor
- GHz sinusoidal gate (SPAD-dummy balancing approach)
 - Very low afterpulsing (< 1.5%)
 - High count rate (> 600 Mcount/s)
- Compact modules based on fast-gating ASIC
 - Trade-off between standard modules and GHz gating)

This work was funded by the projects **EMPIR 14IND05 MIQC2 (H2020)** and **DARPA REVEAL**:



Waiting for you at Single Photon Workshop 2019 in Milano!